



FINAL DRAFT International Standard

ISO/FDIS 30011

Workplace air — Determination of metals and metalloids in airborne particulate matter by inductively coupled plasma mass spectrometry

*Air des lieux de travail — Détermination des métaux et
métalloïdes dans les particules en suspension dans l'air par
spectrométrie de masse avec plasma à couplage inductif*

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Foreword

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The procedures used to develop this document and those intended for its further maintenance are described in the ISO/IEC Directives, Part 1. In particular, the different approval criteria needed for the different types of ISO document should be noted. This document was drafted in accordance with the editorial rules of the ISO/IEC Directives, Part 2 (see www.iso.org/directives).

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For an explanation of the voluntary nature of standards, the meaning of ISO specific terms and expressions related to conformity assessment, as well as information about ISO's adherence to the World Trade Organization (WTO) principles in the Technical Barriers to Trade (TBT), see www.iso.org/iso/foreword.html.

This document was prepared by Technical Committee ISO/TC 146, *Air quality*, Subcommittee SC 2, *Workplace atmospheres*.

This second edition cancels and replaces the first edition (ISO 30011:2010), which has been technically revised.

The main changes are as follows:

- references and definitions have been updated;
- data in [Tables 2](#) and 4 have been updated;
- a new [Annex B](#) has been added containing example instrument operating parameters for standard and collision modes (the previous [Annexes B](#) and [C](#) have been renumbered as [Annexes C](#) and [D](#), respectively);
- a new [Annex E](#) has been added containing substrate-specific detection and quantification data.

Any feedback or questions on this document should be directed to the user's national standards body. A complete listing of these bodies can be found at www.iso.org/members.html.

Introduction

The health of workers in many industries is at risk through exposure by inhalation of toxic metals and metalloids. Industrial hygienists and other public health professionals need to determine the effectiveness of measures taken to control workers' exposure, and this is generally achieved by taking workplace air measurements. This document has been published in order to make available a method for making valid ultra-trace exposure measurements for a wide range of metals and metalloids in use in industry. It is intended for:

- agencies concerned with health and safety at work;
- industrial hygienists and other public health professionals;
- analytical laboratories;
- industrial users of metals and metalloids and their workers.

This document specifies a method for the determination of the mass concentration of metals and metalloids in workplace air using quadrupole inductively coupled plasma mass spectrometry (ICP-MS). For many metals and metalloids, analysis by ICP-MS is advantageous when compared to methods such as inductively coupled plasma atomic emission spectrometry, due to its sensitivity and the presence of fewer spectral interferences.

The execution of the provisions of this document and the interpretation of the results obtained is assumed to be entrusted to appropriately qualified and experienced people.

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